TECHNICAL SPECIFICATIONS FOR

PLC-IPC Interfaced DC SPUTTERING SYSTEM

Description: The DC Sputtering unit will be comprised of a two numbers of 2" magnetron for Sputtering. The vacuum system consisting of turbo molecular pump and dry scroll pump together with system of valves and vacuum measuring hardware's. The system shall be compatible to clean room facility.

Details about the	techr	nical s	pecifications	are	given	below:

SI.	Items		Specifications
No			
1	Sputtering Chamber	(A)	 VACUUM CHAMBER: Box type Stainless Steel (SS) chamber, to accommodate 2" dia. magnetron in the sputter-up configuration. Chamber size: Approximately 500 mm (W) X 500 mm (D) X 450 to 500 mm (H) [minimum requirement]. Chamber should have front door openings for easy access of all the chamber gadgetries. A front opening quick access door is provided for loading & unloading of the substrates. One high vacuum compatible, toughened glass view port with a manual shutter to avoid material deposition on the view port is provided on the door. Chamber must have removable stainless steel shields for easy cleaning. Necessary ports required for Pumping, Sputtering sources, Gas Inlet, Valves, gauges, feedthrough. Baking facility for the whole chamber up to 100°C Provision for adding Load lock chamber with transfer arm as a future up gradation.
		(B)	 MAGNETRON SOURCES Two numbers of 2" indirectly water cooled, flexible sputter source. High power Nd-Fe-B magnets, which are isolated from the water. Easy to change target without breaking any internal seals. User-adjustable tilt angle (±45°) with respect to the plane of the substrate. Stainless steel cross contamination shield should be provided for avoid cross contamination from each other sources.

	(C)	 Two numbers of electro-pneumatically operated source shutters with rotary shaft seal, to cover the sputtering sources should be provided. Water interlock protection should be provided. Provision should be provided to add one more magnetron in future. DC POWER SUPPLIES: Two numbers of 1 KW DC power supply. Power supply should be "European union The Restriction of Hazardous"
		Substances (EU RoHS)" compatible.
	(E)	 SUBSTRATE HEATER Substrate holder to handle up to 3 inch diameter substrate.
		Provision for substrate heating from room temperature to 800 degree Celsius with proportional integral derivative (PID) controller.
		The substrate heater should be oxygen compatible up to maximum temperature.
		 Temperature accuracy should be within ±5 Deg.C Substrate holder shall have provision for substrate rotation 0-60 RPM.
	(F)	 MASS FLOW CONTROLLER Three numbers of Mass Flow Controllers (MFCs for Argon, Oxygen and Nitrogen (2-100sccm) with necessary accessories should be provided. Accuracy (incl. linearity) should be: standard: ±0,5% Rd plus ±0,1%FS.
2 Vacuum	(A)	VACUUM PUMP:
2 Vacuum Pumping System		 The vacuum pumping system should consist of turbo molecular pumping system (having the pumping speed of 400 Ltrs/sec or better) backed by appropriate dry scroll vacuum pump (displacement capacity of 15 m³/hr or better), it should be capable of achieving 1 x 10⁻⁶ mbar pressure. Ultimate vacuum should be better than 1 x 10⁻⁶ mbar range can be achieved in clean, at 25 °C, degassed, chamber after high vacuum valve opens and initially back filled with pure and dry Argon / Nitrogen gas. 2x10⁻⁶ mbar pressure should be achieved in less than 60 minutes.
	(C)	HIGH VACUUM VALVE:
		 Electro-pneumatically operated 3 position gate valve should be operated in throttling mode during sputtering process

		(D)	VACUUM VALVES:
			 Electro pneumatically operated right angle valves for
			roughing, backing process should be provided.
			> Electro magnetically operated Vent valve should be
			provided.
		(E)	SS Plumbing line &Collar
			> SS Plumbing line with flexible hoses & KF connections
			wherever required with necessary interlocks should be
		(E)	provided. VACUUM GAUGES:
		(F)	 Two numbers of Active Pirani gauge head sensor for
			monitoring a vacuum range of 1000 mbar to 1 x 10⁻³
			mbar with accuracy of 15% and one number of
			inverted magnetron Gauges sensor for monitoring a
			vacuum range of 10⁻² mbar to 10⁻⁸ mbar, with
			accuracy of 30%.
3	Control	(A)	> A standalone 19" Industrial standard control console to
	Console &		house all the displays of industrial personal computer
	Instrumentatio		(IPC), Power Supplies, Substrate heater, Substrate
	n		rotation, MFC controller, vacuum gauges, dry scroll pump,
			turbo molecular pump, etc.
			It should have graphical user interface to retrieve and enter data.
4	Mounting	(A)	 Main cabinet should be power coated and it should have
	Frame /	(7.5)	front and back side door for easy servicing and
	Support Stand		maintenance.
			> Main cabinet should be mounted on 4 castor wheels for
			mobility and easy maneuverability with jack bolt for
			keeping in specified location.
5	System Control	(A)	Programmable logic controller-industrial personal
			computer (PLC-IPC) interfaced for sputtering system
			(such as rotation controller of substrate, sputtering power
			sources, pump down sequence, vent sequence, power
			control, shutter control, substrate heater and any required
			components) by supervisory control and data acquisition
			(SCADA) for complete automatic user-friendly operation
			with Window based software with necessary data base
			management.
			 Automatic vacuum cycle to start up the system by
			switching on the pump and opening the relative valves
			subject to appropriate interlock.

			 Automatic deposition with user defined recipe. It should allow user to programme the sequence and time of deposition. System Recipe Development And Control Features: Configurable Data logging function, exportable to Excel/compatible software User log also exportable to Excel/compatible software Multilevel of password protection with user assignable access to recipes. Provision for remote diagnostics and software up gradation should be offered along with the system. System control by sequential operation to build up a standard recipe for Vacuum pump down control and shutters. Software with the recipe programming, storage and recall facility.
6	Water Chiller	(A)	Water chiller should be provided for the whole unit with interlocks, tank, etc. Minimum capacity should be 0.5TR, 30 LTR.
7	Air compressor	(A)	Reciprocating type, Single Stage, 1HP Motor, 4CFM Air compressor, should be provided for the whole unit with interlocks, pressure regulator, tank, etc.
8	Warranty	(A)	> 36 months from the date of commissioning
9	Eligibility Criteria (mandatory)	(A)	 Must have supplied minimum 5 nos. of similar equipments to Government labs / Govt. Institutions / Universities, etc., including any one the Indian Institute of Technology (IITs) in past 5 years. List of Organization names with user details to be submitted along with offer where similar type supplied earlier to above said institutions / Universities / etc Supplier will support the user with all the spares for a minimum period of 10 years. Local Service (Chennai Based) should be available. Detail of experienced service engineer including contract detail should be provided in tender document. Bidder must provide original test report, original warranty certificate and copy of invoice with the system for OEM for all imported items. Bidder shall have to submit audited accounts (Balance sheet profit and loss account) of financial year 2014-15, 2015-16, 2016-2017, and 2017-2018. Audited statement must be signed and stamped by qualified

				chartered accounted.
				Income Tax return for assessment year – 2015-16,
			Í	2016-17 and 2017-18.
				Up to date sales tax clearance certificate.
				Coating Sample with uniformity and thickness
			Í	measurement report should be submitted along
				with the bid.
				The thickness uniformity $\pm 5\%$ or better for 1"
				substrate.
10	Deposition	(A)	٨	Bidders, who satisfy above criteria, would be notified
	Demonstration			about live demonstration. Live demonstration should be
				performed within 30 days after receiving notification.
				Supplier must demonstrate AUTO deposition mode at
				their manufacturing facility: 1) Automatic vacuum cycle to
				start up the system by switching on the pump and
				opening the relative valves subject to appropriate
				interlock. 2) Titanium Nitride deposition for user-defined
				time and power on magnetrons, by reactive sputtering
				with Nitrogen flow of fixed standard cubic centimeters per
				Minute (sccm) defined by user, followed by Nickle
				deposition for user defined time and power. Above cycle
				should be repeated for user-defined number of times.
				Deposition should be done on Silicon substrate with
				substrate rotating at fixed RPM and heated to fixed
				temperature. All the user-defined values would be
				indicated at time of live demonstration. Quality of the film
				would be determined by measuring interface roughness
				and consistency in thickness of all layers. Only upon
				successful demonstration of deposition of good
				quality (thickness uniformity $\pm 5\%$ or better for 1"
				substrate) film, bidder would qualify technical bid.
11	Drawings	(A)	R	Concentual Drawings (over Schematic drawing of whole
111	L'awiiys			Conceptual Drawings (exm: Schematic drawing of whole unit) and Technical brochures must be submitted along
				with the unit.
12	Utilities	(A)	Δ	Details to be provided in the offer for space, power
12				supply, gases, etc for system operation
13	Manuals	(A)	4	Operation Manual to be given after installation and
1.7				acceptance of equipment
14	User Training	(A)		Training for 2 users from IIT madras should be provided
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				components and successful growth of the thin films using
				the given deposition units.
15	Safety and	(A)	\triangleright	Electrical overload protection should be provided.
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	Interlocks		 Mains Indication lamp should be provided. Emergency ON/OFF Switch should be provided. Safety panel switches to cut off source power supply, if doors open should be provided. Vacuum switch interlocked with source power supply for avoiding switching-ON of Power sources without vacuum should be provided. All major components should be connected through circuit breaker and contactor All major electrical circuit should be provided with fuse. 	
16	Spares (Quoted as optional)	(A)	Quote for list of spares and consumables for 3 years operations, should be provided.	
17	All voltages should be compatible with Indian conditions (220-240 V AC with 50 Hz) and similar conditions for three phase supply, if required. Price should include installation charges			